

<b>INFORMATION DISCLOSURE CITATION</b> <i>(Use several sheets if necessary)</i>	Docket Number (Optional) <b>5035-228US/P32,083USA</b>	Application Number <b>10/561490</b>
	Applicant(s) <b>JAP20 Rec'd PCT/PTO 20 DEC 2005</b>	
	Filing Date <b>Herewith</b>	Group Art Unit

**U.S. PATENT DOCUMENTS**

*EXAMINER INITIAL	REF	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
/J.H./	A	6,185,580	02/06/2001	Day, III, et al.	707	205	

**U.S. PATENT APPLICATION PUBLICATIONS**

*EXAMINER INITIAL	REF	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE

**FOREIGN PATENT DOCUMENTS**

	REF	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	Translation	
							YES	NO
/J.H./	1	EP 1 122 647 A	2001-08-08		G06F	15/403	✓	
/J.H./	2	EP 0 526 035 A2	1993-02-03		G06F	12/10	✓	

**OTHER DOCUMENTS** *(Including Author, Title, Date, Pertinent Pages, Etc.)*


EXAMINER <div style="text-align: center;">/Shyue Jiunn Hwa/</div>	DATE CONSIDERED <div style="text-align: center;">08/15/2007</div>
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**EXAMINER:** Initial if citation considered, whether or not citation is in conformance with MPEP Section 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.